
(12) UK Patent Application (19) GB (11) 2 030 575 A

(21) Application No 7927178

(22) Date of filing 3 Aug 1979

(23) Claims filed 3 Aug 1979

(30) Priority data

(31) 53/096803

53/136536

(32) 9 Aug 1978

6 Nov 1978

(33) Japan (JP)

(43) Application published

10 Apr 1980

(51) INT CL³

C08F 8/28

(52) Domestic classification

C3J CT

C3W 301

C3Y B390 B393 F210

H660

(56) Documents cited

GB 1449157

GB 1446981

GB 1329665

GB 1284252

Chemistry Letters (1978)

pp 1289-1292

(58) Field of search

C3J

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(54) Photosensitive resin and method
for manufacture thereof

(57) A photosensitive resin is
produced by causing a styrylpyridinium
salt possessing a formyl group or an
acetal group to react upon polyvinyl
alcohol.

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SPECIFICATION

Photosensitive resin and method for manufacture thereof

5 This invention relates to a photosensitive resin of high solubility in water and high sensitivity and to a method for the manufacture of this resin.

10 Photosensitive resins have been used as raw materials for printing plates, as photoresists for photo-etching and photomilling operations and as photosensitive vehicles for paints and printing inks. In recent years, studies have been conducted on the use of these resins for the immobilization of

15 enzymes.

The photosensitive resins which have been known are those having azide group, cinnamoyl group, acryloyl group, etc. as their photosensitive residues. As immobilizing carriers for enzymes, however,

20 these conventional photosensitive resins are not considered to be satisfactory because they have serious problems such as the adverse effects they bring about on enzymes and the solubility they exhibit in water.

25 The screen printing technique involves spreading gauze on a frame, forming on the gauze a membrane having patterns and effecting printing through the patterns.

Ammonium dichromate-polyvinyl alcohol has

30 generally been used as a photosensitive resin solution for use on a screen printing plate. However, this resin solution has disadvantages in that upon application to gauze, dark reaction of the resin proceeds rapidly and in that industrial pollution is caused due

35 to hexa-valency chromium.

A photosensitive resin solution having a composition of polyvinyl alcohol di-azo groups has also been used. However, this resin solution has disadvantages in that the membrane formed by applying this

40 resin solution to gauze exhibits lower photosensitivity than that formed by use of the above-mentioned ammonium dichromate-polyvinyl alcohol and in that dark reaction of these di-azo groups proceeds gradually though later than that of the above-

45 mentioned ammonium dichromate.

That is to say, a photosensitive resin solution for screen printing is required (1) to have no metal incorporated therein which can possibly cause industrial pollution from an environment;

50 conservation point of view, (2) to prevent dark reaction of the resin and (3) to form a membrane exhibiting higher photosensitivity than the conventionally known photosensitive agents so as to obtain an advance in operation efficiency.

55 As a photosensitive high-molecular compound suitable for such new uses, the inventors formerly synthesized polymers possessing a styrylpyridinium group by the reaction of styrylpyridiniums with the polymer of 2 - chloroethyl vinyl ether and demonstrated this polymer to be suitable for the photo-immobilization of enzymes [Ichimura and Watanabe: Collection of Manuscripts II for the 37th

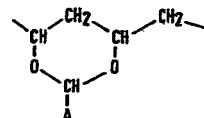
Spring Annual Meeting of the Japan Chemical Society, page 1133 (1978) and Chemistry Letters, page 65 1289 (1978)].

The inventors continued an advanced study with a view to further improving the photosensitivity of this polymer. As a result, they have ascertained that the desired improvement is attained by causing a polyvinyl alcohol to incorporate therein a styrylpyridinium group. The present invention has issued from this knowledge.

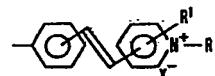
An object of this invention is to provide a novel photosensitive resin which possesses high solubility in water and high sensitivity and, therefore, is suitable as a photoresist, a photosensitive vehicle and a screen printing plate and also as an immobilizing carrier for enzymes.

Another object of this invention is to provide a method for the manufacture of the novel photosensitive resin described above.

According to the present invention, there is provided a photosensitive resin comprising a polyvinyl alcohol derivative having incorporated therein a constituent unit of the generic formula:



90 wherein, A is one member selected from the group consisting of
(A) a group of the generic formula:



95 100 wherein, R represents one member selected from the class consisting of a hydrogen atom, alkyl groups and lower hydroxylalkyl groups, R' one member selected from the class consisting of a hydrogen atom and alkyl groups and X- a strongly acidic ion, and
(B) a group of the generic formula:



110 115 wherein, R1 represents one member selected from the class consisting of a hydrogen atom, alkyl groups and aralkyl groups, R2 one member selected from the class consisting of a hydrogen atom and alkyl groups, n an integer having a value between 1 and 6 inclusive and X- a strongly acidic ion.

The invention also provides a method for the manufacture of the above-mentioned photosensitive resin, which method comprises causing one

120 member selected from the group consisting of polyvinyl alcohols and partially saponified polyvinyl acetates to react with one member selected from the group consisting of
(1) styrylpyridinium salts possessing a formyl group

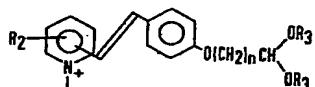
and represented by the generic formula:

5



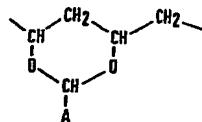
wherein, R represents one member selected from the class consisting of a hydrogen atom, alkyl groups and lower hydroxylalkyl groups, R' one member selected from the class consisting of a hydrogen atom and alkyl groups and X⁻ a strongly acidic ion, and
 10 (2) styrylpyridinium salts possessing an acetal group and represented by the generic formula:

20



wherein, R represents one member selected from the class consisting of a hydrogen atom, alkyl groups and aralkyl groups, R₂ one member selected from the class consisting of a hydrogen atom and alkyl groups, two R₃'s one member selected from the class consisting of an alkyl group and a phenyl group in their respective forms and in a combined form an alkylphenyl group, n an integer having a value between 1 and 6 inclusive and X⁻ a strongly acidic ion.
 30 The photosensitive resin of the present invention has a chemical structure formed of a polyvinyl alcohol derivative having incorporated therein a photosensitive group of the following generic formula.

35



40

wherein, A represents either a group of the generic formula

45



or a group of the generic formula

50



where, R represents one member selected from the class consisting of a hydrogen atom, alkyl groups and lower hydroxylalkyl groups, R' one member selected from the class consisting of a hydrogen atom and alkyl groups, R, one member selected from the class consisting of a hydrogen atom, alkyl groups and aralkyl groups, R₂ one member selected from the class consisting of a hydrogen atom and alkyl groups, X⁻ a strongly acidic ion and n an integer having a value between 1 and 6 inclusive.
 60 Hereinafter, the generic formula:

65



70 will be denoted as S and the generic formula:



75 as T.

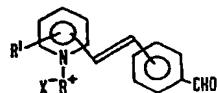
The words "polyvinyl alcohol derivative" as used in the present specification shall mean polyvinyl alcohols and partially saponified polyvinyl acetates and, thus also embraces mixtures containing the polymers of both vinyl alcohol and vinyl acetate.

80 The photosensitive resin of the present invention, therefore, has as its essential constituent units, the aforementioned photosensitive group and the group constituting the aforementioned polyvinyl alcohol derivative. The ratio of these constituent units, specifically the ratio (molar) of the photosensitive group unit to the vinyl alcohol group unit or vinyl acetate group units is desired to fall in the range of from 0.5:99.5 to 10:90. Although the photosensitive group in the photosensitive resin possesses hydrophilicity in itself, the resin loses its solubility in water when the photosensitive group unit is present in excess of the upper limit. The proportion of the photosensitive group unit present in the resin, however, can be raised past the upper limit when a polar solvent such as an aqueous alcohol, dimethylformamide, formamide or dimethylsulfoxide or a mixed solvent consisting of such a polar solvent and water as the solvent.

90 100 The photosensitive resin of the present invention is a novel substance which exhibits high solubility in water and high sensitivity. In an aqueous solution, the photosensitive resin shows the absorption maximum in the ultraviolet spectrum in the neighborhood of 340 nm where the photosensitive group S is used or 360 nm where the photosensitive group T is used. This resin is insolubilized on exposure to a light having a wavelength of up to 460 nm in the former case or up to 500 nm in the latter case.

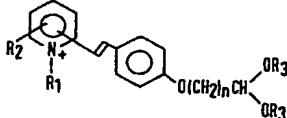
105 110 The photosensitive resin of the present invention can be produced by reacting a polyvinyl alcohol or a partially saponified polyvinyl acetate with a styrylpyridinium salt possessing a formyl group of the generic formula:

115



120 (wherein, R, R' and X⁻ are as defined above) or a styrylpyridinium salt possessing an acetal group of the generic formula:

125

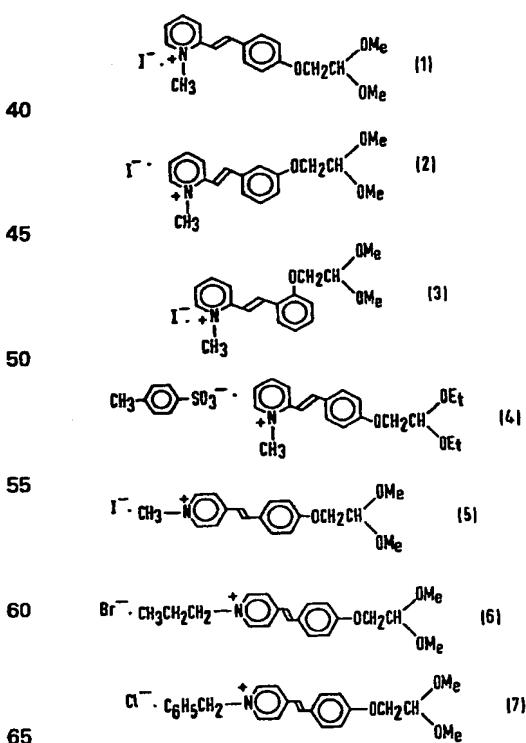


130

(wherein, R_1 , R_2 , n and X^- are as defined above and the two R_3 's each represent an alkyl group or a phenyl group or, in a combined form, represent one alkenyl group).

5 The styrylpicolinium salt to be used as the raw material for the photosensitive resin of this invention is a novel compound. Examples of such styrylpicolinium salts possessing a formyl group include α - (p - formylstyryl) - pyridinium, γ - (p - formylstyryl) - pyridinium, α - (m - formylstyryl) - pyridinium, N - methyl - α - (p - formylstyryl) - pyridinium, N - methyl - β - (p - formylstyryl) - pyridinium, N - methyl - α - (m - formylstyryl) - pyridinium, N - methyl - α - (o - formylstyryl) - pyridinium, N - ethyl - α - (p - formylstyryl) - pyridinium, N - (2 - hydroxyethyl) - α - (p - formylstyryl) - pyridinium, N - (2 - hydroxyethyl) - γ - (p - formylstyryl) - pyridinium, N - allyl - α - (p - formylstyryl) - pyridinium, N - methyl - γ - (p - formylstyryl) - pyridinium, N - methyl - γ - (m - formylstyryl) - pyridinium, N - benzyl - α - (p - formylstyryl) - pyridinium, N - benzyl - γ - (p - formylstyryl) - pyridinium and N - carbamoylmethyl - γ - (p - formylstyryl) - pyridinium. These quaternary salts may be present in the form of hydrochlorides, hydrobromides, hydroiodides, perchlorates, tetrafluoroborates, methosulfates, phosphates, sulfates, methane-sulfonates and p - toluene - sulfonates. These compounds are obtained by subjecting the corresponding picolines or N - alkyl - picolinium salts to the condensation with aromatic dialdehydes or formyl - benzaldehydes, and they are used in the form of formylstyrylpicoline salts or quaternized salts.

10 Examples of the styrylpicolinium salts possessing an acetal group include those listed below.



derivative concentration in the reaction is in the range of from 2 to 20 W/W%.

The progress of the polymer reactions can be traced by precipitating the polymer in alcohol and 5 determining the absorbance due to the styryl-pyridinium group in the neighborhood of 340 nm.

The reaction solutions increase photosensitivity as the reaction proceeds. The progress of this reaction, therefore, can easily be traced measuring the degree 10 of photosensitivity of the reaction solution.

In either case, the solution obtained on completion of the reaction can be used, without purification as a photosensitive liquid of high sensitivity. Desired purification of the resin is accomplished after completion of the reaction by pouring the resultant reaction mixture into a large volume of a non-solvent such as acetone, ethanol or dioxane or a coagulation bath containing such substance as sodium sulfate or potassium sulfate and thereby precipitating the 15 photosensitive resin, separating the precipitated resin from a solvent or a bath and washing the separated resin with alcohol. Thorough removal of the trace of the acid used as the catalyst is attained by washing the resin with alcohol containing a small 20 amount of ammonia or giving the resin repeated reprecipitation.

The photosensitive resin of this invention which contains the photosensitive group S is soluble in water and exhibits high sensitivity. It has a sensitivity equal to or some tens of times as high as that of polyvinyl cinnamate sensitized with 5-nitro-30 acenaphthene. No other resin has been heretofore known to acquire amply high photosensitivity as the result of the incorporation of a photosensitive group 35 in a very low proportion without use of any additional sensitizer. The resin of the present invention proves to be quite economic because it effectively functions with a very small content of the photosensitive group.

40 In the case of the resin of this invention which contains the photosensitive group T, the absorption zone expands in the direction of increasing wavelength and comes to exhibit increased sensitivity because the oxy group is directly linked and conjugated with the styrylpyridinium group. This resin has the sensitivity equal to or ten-odd times as high 45 as that of polyvinyl cinnamate sensitized with 5-nitroacenaphthene. The photosensitive group need be present in the resin only in extremely low amounts in the neighborhood of 1 mol % and, the 50 resin is characterized by acquiring amply high photosensitivity without use of any additional sensitizer. The sensitivity of the resin is not affected at all by temperature; virtually no difference is found between that at 80°C and that at -76°C, for example.

55 By suitable adaptation of the characteristic properties described above, the photosensitive resins of the present invention can be made useful as photo-resists, photomilling agents and other printing stocks, as bases for water paints and as vehicles for printing inks. Further, because the points of crosslinking are attained through dimerization of styryl-pyridinium groups and, therefore, the crosslinking reaction proceeds in a specific manner in the resin, 60 this resin proves to be highly useful as an immobiliz-

ing carrier for biofunctional materials such as enzymes, sectioned live cells and microorganisms. In view of the adhesive strength inherent in its polyvinyl alcohol unit, the resins also prove to be 65 useful as adhesives and binders of the type allowed to manifest their latent properties in an enhanced manner upon exposure to light.

The photosensitive resin of the present invention can be made useful as a membrane for use in screen printing. The photosensitive resin having a high-molecular emulsion mixed therewith can also be used as the membrane.

Typical examples of high-molecular emulsion include vinylacetate emulsion, acryl emulsion, 70 ethylene - vinylacetate emulsion, ethylene - acryl emulsion, SBR latex, silicone resin emulsion, vinyl chloride emulsion and vinylidene chloride emulsion.

The mixing ratio of the solid phase of the emulsion to the polyvinyl alcohol derivative of the present invention having a photosensitive group is desirably 1:0.05-2. The mixture may generally be composed of 0.01-3 part by weight of the solution having 5-20% by weight of a resin per part of a high-molecular emulsion having 20-70% of solid 85 phase. As occasion demands, a thickener or a small amount of dye may further be mixed with the photosensitive resin of the present invention. The addition of such dye makes it easy to detect the presence of pinholes.

90 95 The emulsive, photosensitive compound of the present invention can be preserved for a long period of time and eliminates the disadvantages of the existing method wherein a photosensitive agent and an emulsion are mixed immediately before the mixture is put to practical use since the compound can be used as a photosensitive solution without requiring such mixing treatment.

Now, the present invention will be described more specifically by reference to working examples thereof. 105 Examples 1-6 concern raw materials for the resins of the present invention and Examples 7-26 the resins of the invention.

Example 1:

In a mixed solution consisting of 22.4 g of acetic 110 anhydride and 12.0 g of glacial acetic acid, 18.6 g of α -picoline and 33.5 g of terephthal dialdehyde were dissolved and refluxed under application of heat for eight hours. The resultant reaction solution was cooled, then dissolved in 200 ml of dichloromethane, 115 washed with water and washed again with a diluted aqueous alkali. Subsequently, the reaction product was extracted repeatedly with 1N hydrochloric acid and the extracted product, upon alkalization, immediately gave rise to precipitation of crystals.

120 The crystals were separated by filtration and dried. The crystalline product was dissolved in hot methyl cyclohexane, freed from insoluble material by decantation and recrystallized. Consequently, there were obtained 30.2 g of γ -(p-formylstyryl)-125 pyridine crystals having a melting point of 84 to 86.5°C. By the same procedure, but using γ -picoline and the dialdehyde, γ -(p-formylstyryl)-pyridine having a melting point of 111 to 113°C was obtained.

Example 2:

130 In 80 ml of ethyl acetate, 10.0 g of α -(p-formyl-

tyryl) - pyridine and 7.2 g of dimethyl sulfate were dissolved and refluxed under application of heat for five hours. Two hours after the completion of the reaction, the reaction solution was cooled. The reaction product was separated by filtration, washed with ethyl acetate and dried. Consequently, there was obtained 15 g of yellow N - methyl - α - (p - formylstyryl) - pyridinium methosulfate having a melting point of 151 to 154°C.

10 Example 3:
In 20 ml of ethanol were hot dissolved 5.00 g of N - methyl - α - picolinium p - toluenesulfonate and 10.0 g of terephthal dialdehyde. The resultant mixture, after addition thereto of five drops of piperidine, was refluxed for three hours. The resultant reaction solution was cooled, freed from about 10 ml of ethanol through distillation under vacuum, mixed with ethyl acetate to give rise to a yellow precipitate. The precipitate was separated by decantation and washed twice with ethylacetate. When this separated precipitate was dissolved in hot ethanol and gradually mixed with ethyl acetate, there were precipitated bright yellow crystals. The crystals, when separated by filtration, washed with ethyl acetate and dried, produced 5.57 g of N - methyl - α - (p - formylstyryl) - pyridinium p - toluenesulfonate.

15 Example 4:
In 50 ml of methanol were dissolved 50 g of p - hydroxybenzaldehyde and 23 g of potassium hydroxide. The resultant was freed from the solvent through distillation under vacuum and then dried, to produce a potassium salt. This salt was dissolved in 60 ml of N - methylpyrrolidone, mixed with 70 g of chloroacetaldehyde dimethyl acetal and refluxed at 20 150°C for 15 hours. The resultant reaction solution was cooled, mixed with 200 ml of dichloromethane, washed three times with water and then washed twice with 50 ml of an aqueous 20 weight % caustic soda solution to extract the unreacted portion of 25 hydroxylaldehyde. The organic layer was washed once with water, dried over anhydrous potassium carbonate and then freed from dichloromethane through distillation under vacuum. When the residual oil was distilled under vacuum, there were 30 obtained N - methylpyrrolidone (bp₃ 135°C) and then p - formylphenoxyacetaldehyde dimethylacetal (bp₃ 145°C). The product obtained through the redistillation totalled 34.2 g.

35 Example 5:
In 10 ml of 2 - ethoxyethyl alcohol were dissolved 4.88 g of m - hydroxybenzaldehyde and 1.65 g of caustic soda. The resultant solution, after addition thereto of 7.4 g of bromoacetaldehyde dimethylacetal, was refluxed for 20 hours. The resultant reaction solution was cooled, mixed with benzene, washed once with water and then washed with a dilute alkali solution until the hydroxylaldehyde was completely removed. When the benzene solution was desiccated over anhydrous potassium carbonate and then distilled, there was obtained 3.6 g of m - formylphenoxyacetaldehyde dimethyl acetal (bp₃ 138°C). By repeating this procedure faithfully by using o - hydroxybenzaldehyde, there were obtained o - formylphenoxyacetaldehyde dimethylacetal (bp₃ 60 147°C) and γ - (p - formylphenoxy) - butylaldehyde 65

dimethyl acetal (bp₃ 168°C).

Example 6:

In 7 ml of methanol were dissolved 1.61 g of N - methyl - α - picolinium iodide and 1.70 g of p - formylphenoxyacetaldehyde dimethyl acetal. The resultant mixture, after addition thereto of 0.3 ml of piperidine, was refluxed for four hours. When the reaction solution was cooled, there ensued precipitation of crystals. The crystals were recovered, washed with a small amount of cooled methanol and washed thoroughly with acetone. Thus, there was obtained 2.11 g of 1 - methyl - 2 - {p - (2,2 - dimethoxyethoxy) - styryl} - pyridinium iodide having a melting point of 192 to 197°C. By following the same procedure, but 75 using the n - methyl - α - picoliniumiodide in combination with m - formylphenoxyacetaldehyde dimethylacetal and n - methyl - γ - picolinum p - toluenesulfonate in combination with p - formylphenoxyacetaldehyde dimethylacetal, as the raw 80 materials, there were respectively obtained 1 - methyl - 2 - {m - (2,2 - dimethoxyethoxy) - styryl} - pyridinium iodide having a melting point of 181 to 85 186°C, 1 - methyl - 2 - {o - (2,2 - dimethoxyethoxy) - styryl} - pyridinium iodide having a melting point of 169 to 173°C, and 1 - methyl - 4 - {p - (2,2 - dimethoxyethoxy) - styryl} - pyridinium p - toluenesulfonate having a melting point of 219 to 226°C.

Example 7:

In 28 ml of water, 2 g of partially saponified 90 polyvinyl alcohol (87% of saponification ratio) having a polymerization degree of 500 was dissolved. In the resultant aqueous solution was dissolved 800 mg of 1 - methyl - 2 - (p - formylstyryl) - pyridinium p - toluenesulfonate. The yellow solution which was 95 formed consequently was shaken at 60°C for 15 hours in the presence of 1 g of p - toluenesulfonate added thereto. The shaken mixture was introduced dropwise into a large volume of acetone, and the precipitate produced in the acetone was separated 100 by decantation and washed twice with acetone. The washed precipitate was stirred in ethanol containing a small amount of ammonia for 30 minutes, then 105 separated by filtration and dried. Thus, 1.89 g of a polymer was obtained. In its aqueous solution, this 110 polymer showed a maximum absorption at 337 nm. By use of the absorption coefficient of 1 - methyl - 2 - styrylpyridinium p - toluenesulfonate, this polymer was demonstrated to possess 1.80 mol % of styrylpyridinium unit. A film produced from the aqueous 115 solution produced a clear negative image when it was exposed for 30 seconds to the beam from a 450-W high pressure mercury lamp. The sensitivity of the film relative to the sensitivity of the polyvinyl cinnamate having a polymerization degree of 1700 120 and sensitized with 5 - nitroacenaphthene (10 W/W%) (hereinafter referred to as "relative sensitivity") was 2.5.

Example 8:

In 1 g of an aqueous 10 W/W% solution of 87% 125 saponified polyvinyl alcohol having a polymerization degree of 500, 30 mg of 1 - (2 - hydroxyethyl) - 2 - (p - formylstyryl) - pyridinium chloride was dissolved. The resultant mixture was stirred at 70°C for 12 hours in the presence of 100 mg of p - toluene sulfonic acid added thereto. The resultant reaction solu- 130

tion was introduced dropwise into a large volume of ethanol. The precipitate consequently formed in the solution was separated by filtration, washed with ethanol and dried, to give 92 mg of a product. The

5 content of styrylpyridinium group introduced in the product was 1.50%. The relative sensitivity of the resin was found to be 1.1.

Example 9:

In 2 g of an aqueous 5 W/W% solution of 87% 10 saponified polyvinyl alcohol having a polymerization degree of 500, 80 mg of 1 - methyl - 2 - (p - formylstyryl) - pyridinium p - toluenesulfonate was dissolved. In the presence of 100 mg of 80% sulfuric acid added thereto, the resultant mixture was stirred at 15 60°C for 15 hours. The resultant reaction solution was poured into a large volume of ethanol, and the precipitate formed consequently was separated through four times of decantation and washed with ethanol. The separated precipitate was immersed for 20 30 minutes in ethanol containing a small amount of ammonia. The resin was separated from the bath through filtration, washed with ethanol and dried. Consequently, there was obtained 107 mg of a product having 0.65 mol % of styrylpyridinium unit. The 25 resin's relative sensitivity was found to be 1.3.

Example 10:

To 2 g of an aqueous 5 W/W% solution of 87% 30 saponified polyvinyl alcohol having a polymerization degree of 500, 80 mg of 1 - methyl - 2 - (m - formylstyryl) - pyridinium p - toluenesulfonate was added and the resultant mixture was stirred at 75°C for 15 hours. The resultant reaction solution was poured into a large volume of acetone and then washed through decantation twice with acetone, twice with 35 ethanol and once with ammonia-containing ethanol. Thus, there was obtained 110 mg of a product. By analysis with the ultra-violet absorption spectrometry, the resin was demonstrated to have a styrylpyridinium group content of 1.9 mol %. The 40 film of the resin had a relative sensitivity of 1.5.

Example 11:

In 5 g of an aqueous 5 W/W% solution of 45 thoroughly saponified polyvinyl alcohol having a polymerization degree of 2000, 80 mg of 1 - methyl - 2 - (p - formylstyryl) - pyridinium p - toluenesulfonate was dissolved. In the presence of 200 mg of p - toluene sulfonic acid added thereto, the resultant mixture was stirred at 60°C for 15 hours. The reaction 50 solution obtained consequently was poured into a large volume of acetone, giving rise to a precipitate. This precipitate was dried twice with acetone and once with ethanol and dried. Consequently, 263 mg of a polymer was obtained. The resin was found to have a styrylpyridinium group content of 2.10% and 55 a relative sensitivity of 18.

Example 12:

In 2 g of an aqueous 5 W/W% solution of 87% 60 saponified polyvinyl alcohol having a polymerization degree of 2400, 60 mg of 1 - methyl - 2 - (p - formylstyryl) - pyridinium p - toluenesulfonate was dissolved. The resultant mixture, after addition thereto of 500 mg of p - toluene sulfonic acid, was stirred at 60°C for 15 hours. The resultant reaction solution was introduced dropwise into a large volume of 65 acetone. The precipitate consequently produced was

washed twice with acetone and once with ethanol, then immersed in ammonia-containing ethanol for 30 minutes, separated and dried. Thus, 113 mg of a polymer was obtained. The resin had a styrylpyridinium unit of 2.0 mol%. The film of this resin showed a relative sensitivity of 50.

Example 13:

In 10 ml of water, 200 mg of 87% saponified 70 polyvinyl alcohol having a polymerization degree of 500 was dissolved. The mixture, after addition thereto 40 mg of 1 - methyl - 2 - (p - formylstyryl) - pyridinium iodide and 100 mg of 85% phosphoric acid, was stirred at 60°C for three hours. The reaction solution was immediately poured into a large volume of acetone. The precipitate consequently formed was washed thoroughly three times with methanol and then dried. Thus, 205 mg of a polymer was produced. This resin was found to have a styrylpyridinium unit of 1.7 mol% and a relative sensitivity of 2.0.

Example 14:

In 2 ml of water, 400 mg of 87% saponified 75 polyvinyl alcohol having a polymerization degree of 500 was dissolved. The mixture, after addition thereto of 40 mg of 1 - methyl - 4 - (p - formylstyryl) - pyridinium p - toluenesulfonate and 0.5 g of 85% phosphoric acid, was stirred at 65°C for ten hours. The reaction solution was poured into a large volume of acetone. The precipitate consequently produced was washed four times with methanol and then vacuum dried. Thus, 399 mg of a polymer was obtained. This resin was found to have a styrylpyridinium group unit of 0.70 mol% and a relative sensitivity of 0.7.

Example 15:

In 15 ml of water, 1 g of 87% saponified polyvinyl 80 alcohol having a polymerization degree of 1700 was dissolved. The mixture, after addition thereto of 100 mg of 1 - methyl - 4 - (p - formylstyryl) - pyridinium p - toluenesulfonate and 0.5 g of 85% phosphoric acid, was stirred at 80°C for eight hours. The reaction solution was poured into a large volume of acetone to give rise to a precipitate. The precipitate was thoroughly disintegrated and washed three times 85 with methanol. After it was confirmed that the washings no longer assumed a yellow color, the product was vacuum dried. Thus, 0.95 g of a polymer was obtained. Through absorption spectrometry, this resin was shown to possess the maximum absorption at 343 nm and have a styrylpyridinium group content of 1.02%. The resin showed a relative sensitivity of 12. The film prepared from the reaction solution prior to purification showed a relative sensitivity of 7.

Example 16:

To 10 g of an aqueous 5 W/W% solution of 87% 90 saponified polyvinyl alcohol having a polymerization degree of 1700, 100 mg of 1 - methyl - 2 - (p - formylstyryl) - pyridinium - methosulfate was added. The 95 resultant mixture was thoroughly stirred and mixed with 3 g of 85% phosphoric acid under stirring. Consequently, there was obtained a yellow homogeneous solution. This solution was maintained overnight at 67°C and then poured into a large volume of acetone. The precipitate consequently formed in the 100

solution was collected. This precipitate was washed twice with ethanol and dissolved in water and reprecipitated in acetone for the purpose of purification. Thus, 0.47 g of a resin was obtained. This resin had a 5 styrylpyridinium unit of 1.20 mol% and a relative sensitivity of 3.0.

Example 17:

To a 10 g of an aqueous 5 W/W% solution of 87% saponified polyvinyl alcohol having a polymerization 10 degree of 500, 30 mg of 1 - methyl - 2 - (p - formylstyryl) - pyridinium - methosulfate was added. The mixture was thoroughly stirred and then mixed with 0.5 ml of 6N hydrochloric acid under stirring, to produce a yellow homogeneous solution. This solution 15 was maintained at 70°C for eight hours. The hot solution was poured into a large volume of acetone. The precipitate consequently formed in the solution was washed three times with methanol and then dried. Thus, 482 mg of a resin was obtained. This resin had 20 a styrylpyridinium unit of 0.45 mol% and showed a relative sensitivity of 0.8.

Example 18:

In 10 g of an aqueous 5 W/W% solution of 87% saponified polyvinyl alcohol having a polymerization 25 degree of 1700, 30 mg of 1 - carbamoylmethyl - 4 - (p - formylstyryl) - pyridinium chloride was dissolved. The mixture, after addition thereto of 1 g of 85% phosphoric acid, was stirred at 50°C for ten hours. The resultant reaction solution was poured into a 30 large volume of acetone. The precipitate consequently formed therein was washed four times with methanol and vacuum dried. Thus, 0.45 g of a resin was obtained. This resin had a styrylpyridinium unit of 0.52 mol% and showed a relative sensitivity of 4.0.

Example 19:

In 210 ml of water, 21 g of 87% saponified polyvinyl alcohol having a polymerization degree of 1700 was dissolved by application heat. The solution was homogeneously mixed with 20 ml of water having dissolved in advance therein 2.1 g of 2 - (p - formylstyryl) - pyridine and 3 g of 85% phosphoric acid. The solution was stirred at 70°C for six hours. The reaction solution had a styrylpyridinium unit of 1.26 mol% based on the polyvinyl alcohol. When this 45 reaction solution was applied in its unmodified form to an aluminum plate and the resultant film was exposed to light and then developed with a weakly acidic aqueous solution, there was obtained a clear negative image. The film's relative sensitivity was 50 found to be 6.7.

Example 20:

In 7 ml of water, 500 mg of 87% saponified polyvinyl acetate having a polymerization degree of 1700 was added. Then, 187 mg of 1 - methyl - 4 - {p - (2,2 - dimethoxyethoxy) - styryl} - pyridinium - methosulfate (see Example 6). The resultant solution, after addition thereto of 0.5 ml of 85% phosphoric acid, was stirred at 60°C for 15 hours. The reaction solution showed a high degree of sensitivity 60 in itself. It was further processed as follows to afford a resin. The yellow reaction solution was poured into a large volume of acetone to produce a resin in the form precipitate. The precipitate was thoroughly washed twice with methanol and vacuum dried.

65 Thus, there was obtained 420 mg of resin. The resin,

in its aqueous solution, showed maximum absorption at 370 nm. The resin was estimated to have a styrylpyridinium unit of 2.20 mol% on the basis of the ultraviolet absorption spectrum. This resin was

70 converted into an aqueous solution, applied to an aluminum plate and dried, and the resultant film was exposed through a negative image to the beam from a 450-W high pressure mercury lamp and then developed with water. Consequently there was 75 obtained a clear image. The resin's relative sensitivity was found to be 30.

When the procedure described above was repeated by using the partially saponified polyvinyl acetate and the phosphoric acid in the same amounts as 80 above, except that the amount of the aforementioned pyridinium salt was changed to 97.1 mg in one test run and 49.5 mg in another test run, there were obtained photosensitive polyvinyl alcohol resins having 1.10 mol% and 0.71 mol% respectively 85 of styrylpyridinium unit. These resins were found to have 12 and 9 respectively of relative sensitivity.

Example 21:

In 6 g of an aqueous 8 weight% solution of 87% saponified polyvinyl acetate (having a polymerization 90 degree of 1700), 63 mg of 1 - methyl - 2 - {o - (2,2 - dimethoxyethoxy) - styryl} - pyridinium iodide was added. The resultant mixture, after addition thereto of 150 mg of p - toluene sulfonic acid, was treated at 60°C for 15 hours to induce a reaction. The yellow 95 reaction solution consequently produced was poured into a large volume of acetone. The resin which occurred in the form of precipitate was washed twice with methanol and then dried under vacuum. Thus, 409 mg of purified resin was 100 obtained. The aqueous solution of this resin showed the maximum absorption at 356 nm. On the basis of the absorption coefficient of the pyridinium salt used as the raw material, the resin was estimated to contain 1.43 mol% of styrylpyridinium group. When 105 tested by the gray scale method, this resin showed a relative sensitivity of 2.7. When the procedure described above was repeated by using 33 mg of the pyridinium salt, there was obtained a resin having a styrylpyridinium unit of 0.81 mol%. The relative sensitivity of this resin was 0.6.

Example 22:

In 6 g of an aqueous 8 weight% solution of 87% saponified polyvinyl acetate (having a polymerization 115 degree of 1700), 60.5 mg of 1 - methyl - 2 - {m - (2,2 - dimethoxyethoxy) - styryl} - pyridinium iodide was homogeneously dissolved. The solution, after addition thereto of 150 mg of p - toluene sulfonic acid, was stirred at 60°C for 15 hours. The reaction solution was poured into a large volume of acetone. 120 The resin consequently produced in the solution was washed twice with methanol and then dried under vacuum. Thus, there was obtained 420 mg of a purified resin. The aqueous solution of this resin showed the maximum absorption at 338 nm. On the 125 basis of the absorption spectrum, the resin was estimated to have a styrylpyridinium content of 1.43%. The resin's relative sensitivity was 7.0. When the procedure described above was repeated by using 32.8 mg of the aforementioned pyridinium salt, there 130 was obtained a resin having a styrylpyridinium unit

of 0.82 mol%. The relative sensitivity of this resin was 2.4.

Example 23:

In 6 g of an aqueous 8 weight% solution of 87% saponified polyvinyl acetate (having a polymerization degree of 1700), 61.4 mg of 1 - methyl - 2 - {p - (2,2 - dimethoxyethoxy) - styryl} - pyridinium iodide was dissolved. The solution was mixed with 150 mg of p - toluene sulfonic acid to produce a homogeneous solution, which was treated at 60°C for 15 hours to induce a reaction. The yellow reaction solution thus formed was poured into a large volume of acetone. The resin which occurred consequently was washed twice with methanol and then dried under vacuum. Thus there was obtained 420 mg of a purified resin. The aqueous solution of this resin showed the maximum absorption at 361 nm. On the basis of the absorption spectrum, this resin was estimated to have a styryl/pyridinium unit of 1.27 mol%. This resin had a relative sensitivity of 9.0. When the procedure described above was repeated by using 33.7 mg of the aforementioned pyridinium salt, there was obtained a resin having a styryl-pyridinium unit of 0.75 mol%. It showed a relative sensitivity of 4.0.

Example 24:

In 6 g of an aqueous 8 weight% solution of 87% saponified polyvinyl acetate (having a polymerization degree of 1700), 65.0 mg of 1 - methyl - 2 - {p - (4,4 - dimethoxybutoxy) - styryl} - pyridinium iodide obtained from N - methyl - α - picolinium iodide and γ - (p - formylphenoxy) - butylaldehyde dimethylacetal by the procedure of Example 6 was homogeneously dissolved. The resultant solution, after addition thereto of 150 mg of p - toluene sulfonic acid, was treated at 60°C for 15 hours to induce a reaction. The yellow reaction solution was poured into a large volume of acetone. The resin consequently formed was washed twice with methanol and then dried under vacuum. Thus, there was obtained 430 mg of a purified resin. This resin, in its aqueous solution, showed the maximum absorption at 361 nm. On the basis of the absorption spectrum, the resin was estimated to have a styrylpyridinium unit of 1.05 mol%. The resin's relative sensitivity was 3.2.

Example 25:

10 g of N - methyl - γ - (p - formylstyryl) - pyridinium methosulfate was dissolved in a solution produced by dissolving in 1150 ml of water 100 g of 87% saponified polyvinyl acetate having a polymerization degree of 2000 and then mixed with 5 g of 85% phosphoric acid. The resultant mixture was stirred at 70°C for 5 hours. To 12 g of the resultant reaction solution, 7.5 g of vinylacetate emulsion (Konishi Shoten: Bond-CH-18) was added and fully mixed. The solution thus obtained was applied to gauze of 150 mesh made of Teflon and dried, with the result that a membrane of uniform thickness was formed. The membrane was placed at a position about 50 cm distant from a 450W mercury lamp and irradiated through a negative for two minutes, and thereafter vigorously washed with city water. As a result, a clear image appeared on the membrane. This membrane exhibited about five times the photosensitivity

of a membrane formed by use of a commercially available photosensitive solution of di-azo resin-polyvinyl alcohol.

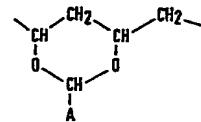
Example 26:

70 A mixed solution of N - methyl - γ - (p - formylstyryl) - pyridinium methosulfate, polyvinyl acetate and phosphoric acid was prepared in the same manner as in Example 25. 1.5 parts by weight of silicone resin emulsion (30% solid phase) per part of this solution was well mixed with this solution. The resultant mixture was applied to gauze of 150 mesh made of Teflon and dried to obtain a membrane. This membrane was irradiated with a super high-pressure mercury lamp and developed with city water. As a result, a clear image appeared on the membrane. This membrane exhibited high strength, high repellence and about ten times the photosensitivity of a membrane formed by use of a commercially available di-azo resin photosensitive agent.

85 CLAIMS

1. A photosensitive resin comprising a polyvinyl alcohol derivative having incorporated therein a constituent unit of the generic formula:

90



95

wherein, A is one member selected from the group consisting of

(A) a group of the generic formula:

100



105 wherein, R represents one member selected from the class consisting of a hydrogen atom, alkyl groups and lower hydroxyalkyl groups, R' one member selected from the class consisting of a hydrogen atom and alkyl groups and X⁻ a strongly acidic ion, and

(B) a group of the generic formula:

115



wherein, R₁ represents one member selected from the class consisting of a hydrogen atom, alkyl groups and aralkyl groups, R₂ one member selected from

120 the class consisting of a hydrogen atom and alkyl groups, n an integer having a value between 1 and 6 inclusive and X⁻ a strongly acidic ion.

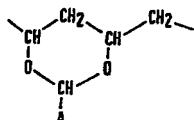
2. The photosensitive resin according to Claim 1, wherein X⁻ represents one member selected from the group consisting of halogen ions, sulfate ion, phosphate ion and p - toluene sulfonate ion.

3. The photosensitive resin according to Claim 1, wherein the polymerization degree of the polyvinyl alcohol falls in the range of from 400 to 3000.

130 4. The photosensitive resin according to Claim 1,

which resin is useful for a screen printing plate.

5. A method for the manufacture of a photosensitive resin comprising a polyvinyl alcohol derivative having incorporated therein a constituent unit of the 5 generic formula:



10

wherein, A is one member selected from the group consisting of
(A) a group of the generic formula:

15



20 wherein, R represents one member selected from the class consisting of a hydrogen atom, alkyl groups and lower hydroxyalkyl groups, R' one member selected from the class consisting of a hydrogen and alkyl groups and X- a strongly acidic ion, 25 and

(B) a group of the generic formula:

30

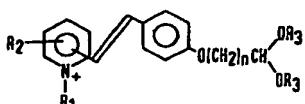
wherein, R₁ represents one member selected from the class consisting of a hydrogen atom, alkyl groups and aralkyl groups, R₂ one member selected from the class consisting of a hydrogen atom and 35 alkyl groups, n an integer having a value between 1 and 6 inclusive and X- a strongly acidic ion, which method comprises causing one member selected from the group consisting of polyvinyl alcohols and partially saponified polyvinyl acetates 40 to react with one member selected from the group consisting of
(1) styrylpuridinium salts possessing a formyl group and represented by the generic formula:

45



wherein, R represents one member selected from 50 the class consisting of a hydrogen atom, alkyl groups and lower hydroxyalkyl groups, R' one member selected from the class consisting of a hydrogen and alkyl groups and X- a strongly acidic ion, and
55 (2) styrylpuridinium salts possessing an acetal group and represented by the generic formula:

60



wherein, R₁ represents one member selected from the class consisting of a hydrogen atom, alkyl groups and aralkyl groups, R₂ one member selected 65 from the class consisting of a hydrogen atom and

alkyl groups, two R₃'s one member selected from the class consisting of an alkyl group and a phenyl group in their respective forms and in a combined form an alkenyl group, n an integer having a value between 1 and 6 inclusive and X- a strongly acidic ion.

70 6. The method according to Claim 5, wherein X- represents one member selected from the group consisting of halogen ions, sulfate ion, phosphate ion and p-toluenesulfonate ion.

75 7. The method according to Claim 5, wherein the styrylpuridinium salt possessing a formyl group is used in a proportion of from 0.3 to 20 mol% based on one vinyl alcohol unit selected from the group consisting of polyvinyl alcohols and partially saponified polyvinyl acetates.

80 8. The method according to Claim 5, wherein the styrylpuridinium salt possessing an acetal group is used in a proportion of from 0.3 to 20 mol% based on one vinyl alcohol unit selected from the group consisting of polyvinyl alcohols and partially saponified polyvinyl acetates.

85 9. A photosensitive resin substantially as hereinbefore described.

10. A method of manufacturing a photosensitive resin substantially as hereinbefore described.

Printed for Her Majesty's Stationery Office by The Tweeddale Press Ltd., Berwick-upon-Tweed, 1980.
Published at the Patent Office, 25 Southampton Buildings, London, WC2A 1AY, from which copies may be obtained.